

1. 2. 3. 4. 5. 6. 7. 8. 9. 10. 11. 12. 13. 14. 15. 16. 17. 18. 19. 20. 21. 22. 23. 24. 25. 26. 27. 28. 29. 30. 31. 32. 33. 34. 35. 36. 37. 38. 39. 40. 41. 42. 43. 44. 45. 46. 47. 48. 49. 50. 51. 52. 53. 54. 55. 56. 57. 58. 59. 60. 61. 62. 63. 64. 65. 66. 67. 68. 69. 70. 71. 72. 73. 74. 75. 76. 77. 78. 79. 80. 81. 82. 83. 84. 85. 86. 87. 88. 89. 90. 91. 92. 93. 94. 95. 96. 97. 98. 99. 100.

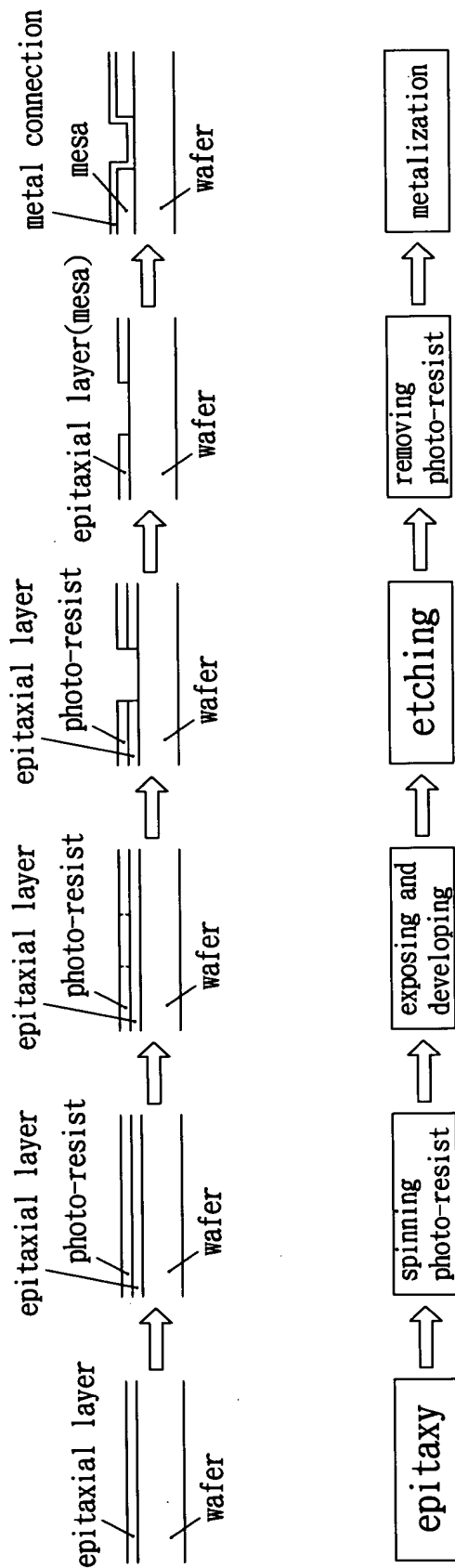


FIG. 1



1. epi taxy
 2. spinning photo-resist
 3. exposing and developing
 4. growing a thick oxide layer
 5. removing photo-resist
 6. metalization

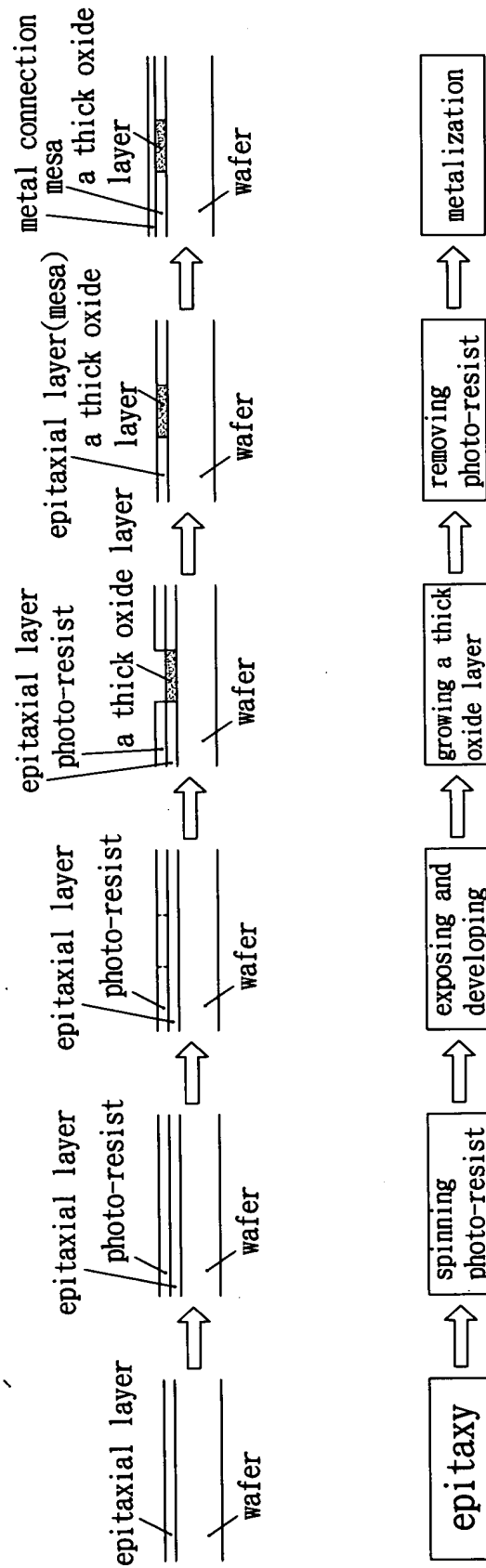


FIG. 3

```

graph LR
    A[epitaxy] --> B[spinning photo-resist]
    B --> C[exposing and developing]
    C --> D[etching]
    D --> E[growing a thin oxide layer]
    E --> F[removing photo-resist]
    F --> G[metallization]
  
```

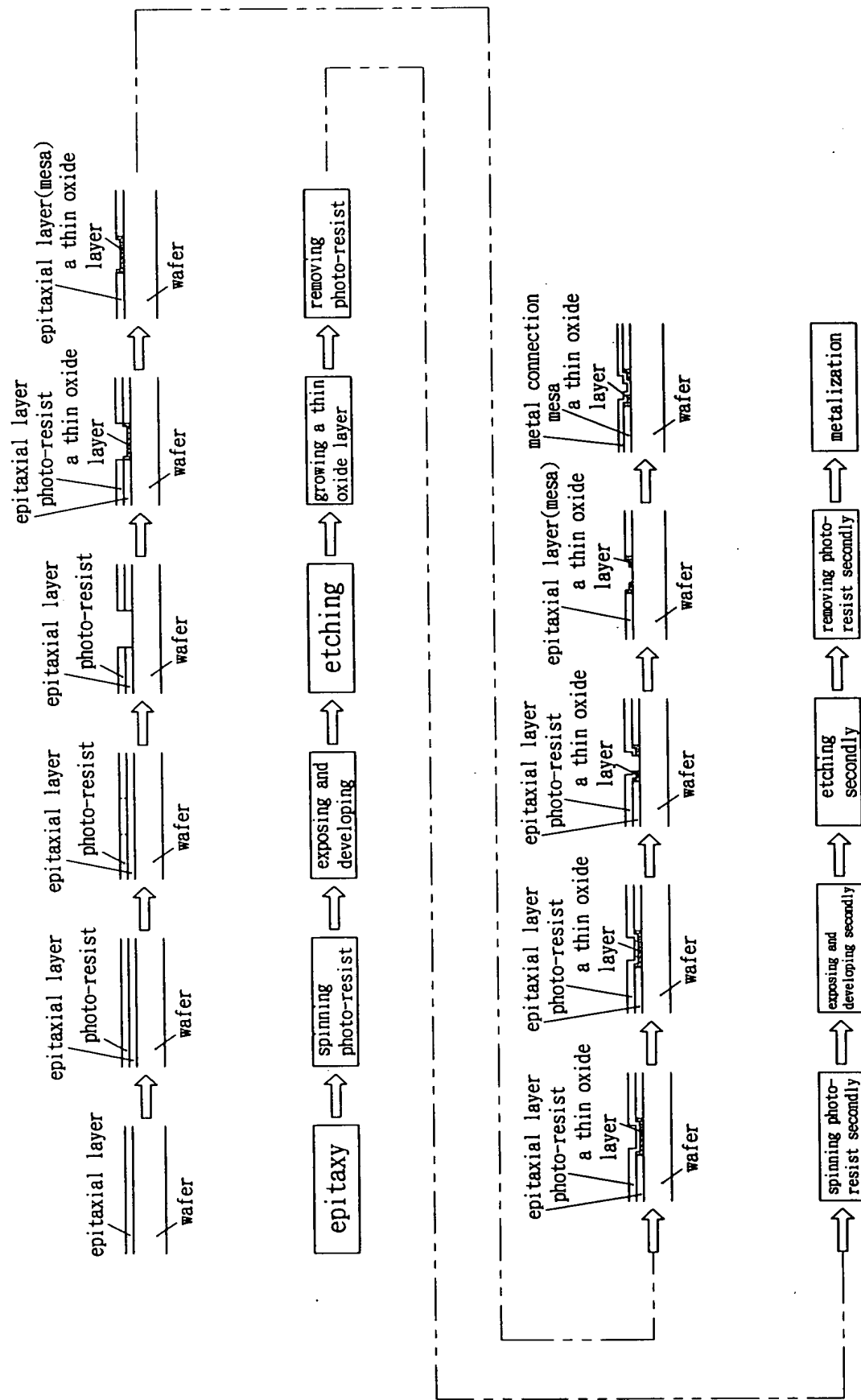


FIG. 5